



Inventor: John T. Moore

Title: Methods of Forming Oxide Regions Over Semiconductor Substrates

Assignee: Micron Technology, Inc.

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Jm willan  
8/20/02

**INFORMATION DISCLOSURE STATEMENT**

References – See Attached Form PTO-1449

The attached form PTO-1449 is submitted in compliance with 37 CFR § 1.56. Copies of the cited art are included. No admission is made regarding whether all the submitted references are prior art.

Respectfully submitted,

Dated:

August 6, 2002

Attorney:

Jennifer J. Taylor  
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